

L Number	Hits	Search Text	DB	Time stamp
1	1	("5118485").PN.	USPAT; US-PGPUB	2003/12/01 11:19
2	93025	CVD (chemical adj vapor adj deposition)	USPAT; US-PGPUB	2003/12/01 11:20
3	96259	\$3CVD (chemical adj vapor adj deposition)	USPAT; US-PGPUB	2003/12/01 11:54
4	2	(\$3CVD (chemical adj vapor adj deposition)) same water with recycle	USPAT; US-PGPUB	2003/12/01 11:22
5	26	(\$3CVD (chemical adj vapor adj deposition)) and water with recycle	USPAT; US-PGPUB	2003/12/01 11:24
6	16	(\$3CVD (chemical adj vapor adj deposition)) and direct\$3 with recycle	USPAT; US-PGPUB	2003/12/01 11:32
7	16	(\$3CVD (chemical adj vapor adj deposition)) with recycle	USPAT; US-PGPUB	2003/12/01 11:32
8	52	(\$3CVD (chemical adj vapor adj deposition)) with recycl\$4	USPAT; US-PGPUB	2003/12/01 11:36
9	1	("4468283").PN.	USPAT; US-PGPUB	2003/12/01 11:43
10	0	(CVD (chemical adj vapor adj deposition)) with recycl\$4	USOCR	2003/12/01 11:44
11	12	(CVD (chemical adj vapor adj deposition))and recycl\$4	USOCR	2003/12/01 11:47
12	128	vapor with direct\$5 with recycle	USOCR	2003/12/01 11:47
13	128	vapor with direct\$5 with recycle	USOCR	2003/12/01 11:48
14	154	vapor with direct\$5 with recycle	USPAT; US-PGPUB	2003/12/01 11:48
15	69	vapor with directly with recycle	USPAT; US-PGPUB	2003/12/01 13:44
16	123	(\$3CVD (chemical adj vapor adj deposition)) and recycl\$5 with water	USPAT; US-PGPUB	2003/12/01 11:54
17	1683	(\$3CVD (chemical adj vapor adj deposition)) and recycl\$5	USPAT; US-PGPUB	2003/12/01 11:55
18	31	(\$3CVD (chemical adj vapor adj deposition)) and recycl\$5 with directly	USPAT; US-PGPUB	2003/12/01 13:42
19	15654	(\$3CVD (chemical adj vapor adj deposition)) and (dipole polar\$7)	USPAT; US-PGPUB	2003/12/01 13:21
20	196	(\$3CVD (chemical adj vapor adj deposition)) with (dipole polar\$7)	USPAT; US-PGPUB	2003/12/01 13:21
21	13	((3CVD (chemical adj vapor adj deposition)) and recycl\$5 with directly) and permeate	USPAT; US-PGPUB	2003/12/01 13:42
22	8	(\$3CVD (chemical adj vapor adj deposition)) with raw with recycl\$5	USPAT; US-PGPUB	2003/12/01 13:47
23	0	(\$3CVD (chemical adj vapor adj deposition)) with unseparated with recycl\$5	USPAT; US-PGPUB	2003/12/01 13:48
24	0	(\$3CVD (chemical adj vapor adj deposition)) and unseparated with recycl\$5	USPAT; US-PGPUB	2003/12/01 14:00
25	0	(\$3CVD (chemical adj vapor adj deposition)) and untainted with recycl\$5	USPAT; US-PGPUB	2003/12/01 14:00
26	0	(\$3CVD (chemical adj vapor adj deposition)) and unprocess\$4 with recycl\$5	USPAT; US-PGPUB	2003/12/01 14:00
27	17	(\$3CVD (chemical adj vapor adj deposition)) and outlet with inlet with direct\$3 near2 (connect\$6)	USPAT; US-PGPUB	2003/12/01 14:15
28	2	(\$3CVD (chemical adj vapor adj deposition)) and outlet with inlet with direct\$3 near2 (coupl\$6)	USPAT; US-PGPUB	2003/12/01 14:15